



9-2009

Piezoresponse Force Microscopy: A Window into Electromechanical Behavior at the Nanoscale

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Bonnell, D. A., Kalinin, S. V., Kholkin, A. L., & Gruverman, A. (2009). Piezoresponse Force Microscopy: A Window into Electromechanical Behavior at the Nanoscale. Retrieved from https://repository.upenn.edu/mse_papers/171

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Piezoresponse Force Microscopy: A Window into Electromechanical Behavior at the Nanoscale. Bonnell DA, Kalinin SV, Kholkin AL, et al. MRS BULLETIN, 34:9, 648-657, SEP 2009

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Keywords

SCANNING PROBE MICROSCOPY, NONLINEAR DIELECTRIC MICROSCOPY, FERROELECTRIC DATA-STORAGE, THIN-FILMS, SINGLE-CRYSTALS, ULTRAHIGH DENSITY, LOCAL REACTIVITY, POLARIZATION, SURFACES, NANOSTRUCTURES

Comments

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Piezoresponse Force Microscopy: A Window into Electromechanical Behavior at the Nanoscale

D.A. Bonnell, S.V. Kalinin, A.L. Kholkin, and A. Gruverman

Abstract

Piezoresponse force microscopy (PFM) is a powerful method widely used for nanoscale studies of the electromechanical coupling effect in various materials systems. Here, we review recent progress in this field that demonstrates great potential of PFM for the investigation of static and dynamic properties of ferroelectric domains, nanofabrication and lithography, local functional control, and structural imaging in a variety of inorganic and organic materials, including piezoelectrics, semiconductors, polymers, biomolecules, and biological systems. Future pathways for PFM application in high-density data storage, nanofabrication, and spectroscopy are discussed.

Introduction

Over the last two decades, scanning probe microscopy has been instrumental in advancing our understanding of fundamental phenomena in many fields, including superconductivity, spin-resolved transport, charge density wave transitions, protein folding, chemical sensing, and catalysis. A particularly interesting case is piezoresponse force microscopy (PFM), which is unique in that it probes a tensorial property, the coupling between electric field and mechanical strain. While the first and most obvious application of this technique is to straightforwardly map domains in ferroelectric materials, PFM does much more both in terms of the information content and of applications. Coupling between electric fields and mechanical strain underpins a broader range of phenomena in ferroelectrics and other polar materials.

This article highlights recent examples in which PFM directly probes electromechanical interactions in systems ranging from complex ferroelectric materials and piezoelectric compounds to biological tissues. These examples also illustrate that creative variants of PFM or a quantitative approach to data analysis contribute to a fundamental understanding of complex phenomena in solids.

Imaging of Ferroelectric Domains: Statics and Dynamics

PFM utilizes a basic experimental setup of atomic force microscopy in which a conducting tip at the end of a cantilever is brought in contact with a piezoelectric sample. When a voltage is applied to the tip, the resulting deformation of the sample is monitored through the mechanical displacement of the cantilever—piezoresponse.

While the concept is straightforward, quantification of properties can be complicated due to the complex sample-probe signal transfer mechanism. Nevertheless, considerable progress has been made in developing protocols for quantitative materials characterization with PFM.¹ It is now routine to map ferroelectric domains based on variations of the amplitude and phase of the piezoresponse to the ac bias applied to the tip.

PFM has been developed as an alternative to electron microscopy in the high-resolution imaging of ferroelectric domains in thin films, which in the case of PFM can be performed in a nondestructive manner. Further development of PFM has been stimulated by the need to understand the mechanism of the switching behavior in ferroelectric structures and devices. Progress in the fabrication of high-quality ferroelectric films resulted in a number of novel applications, including nonvolatile ferroelectric memories used in smart cards and commercial products such as Sony PlayStation, data storage devices, and field-effect transistors, all of which employ switchable polarization. PFM has become an indispensable tool for addressing the statics and dynamics of ferroelectric domains, which are highly relevant both to the fundamental physics of ferroelectrics and to the optimization of device performance. PFM studies of static and dynamic properties of ferroelectric domains are summarized in this article.

Local Switching and Statistical Analysis of Ferroelectric Domain Wall Motion

Ferroelectric materials contain a range of structural defects (e.g., dislocations and oxygen vacancies) that influence local ferroelectric switching by affecting local phase stability and acting as sites for domain wall pinning and nucleation. In the low electric fields, the nucleation is limited to a small number of dominant nucleation centers,² and the kinetics of polarization switching is controlled by the propagation of domain walls. Due to the extremely small thickness of a ferroelectric domain wall, it can effectively interact with local defects, resulting in a broad range of phenomena, including pinning, imprint, and fatigue. The complexity of these dynamic behaviors is reflected in the topological structure of domain walls that exhibit a complicated self-affine structure.³ The fractal dimensionality of a domain wall is directly related to the corresponding universality class and hence contains information on wall dynamics. Traditionally, this universal dynamics has been studied using dielectric spectroscopy

methods that require comprehensive field-dependent measurements to extract the wall dynamics unambiguously. The development of PFM has allowed the exploration of static and dynamic properties of the domain walls locally for length scales from ~ 10 nm to $100 \mu\text{m}$, providing an overview of the geometric structure of the wall in the spatial range of four orders of magnitude.

Geometry of the PFM setup allows application of the switching voltage both through the conductive probing tip or electrodes deposited at the top of the specimen (Figure 1), followed by the imaging of the resulting domain structure. In the case of a highly localized tip-generated field (Figure 1a), the polarization reversal occurs through growth of a single domain nucleated at the tip-surface contact. In epitaxial thin films and crystals, the domain size typically varies linearly with the applied voltage and logarithmically with time.⁴ Two main theoretical models have been proposed to explain the mechanism of lateral domain growth. The first one invokes a thermal activation type of wall motion with an exponential field (E) dependence of the wall velocity,

$$v \sim \exp(-1/E). \quad (1)$$

However, this model adequately describes the experimental results only for a limited range of domain dimensions ($< 1 \mu\text{m}$), while there is a strong deviation between theory and experiment for larger domains. A more general approach suggests that the wall motion is a creep process governed by the pinning potential.^{5,6} The wall velocity exhibits field dependence in the form of

$$v \sim \exp(-1/E)^\mu, \quad (2)$$

with the dynamical exponent μ reflecting both wall dimensionality and the nature of potential disorder. In a periodical potential, μ is close to unity, but it varies widely for random potential distribution. Note that due to the nonuniform field distribution, reliable measurements of the field-dependent wall dynamics in the tip-induced switching are extremely difficult, leading to continuing debates about the mechanism for domain growth. Paruch et al.⁷ introduced an analysis of domain wall roughness in relation to disorder type, and this was later extended to analyze the thermodynamics of the domain formation in ultrathin films.⁸ Tybell et al.⁵ and Pertsev et al.⁶ applied the same approach to study field-dependent domain wall kinetics. The studies by Likodimos et al.^{9,10} and later by

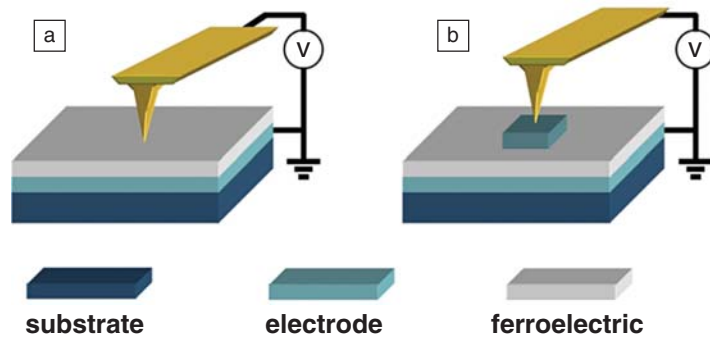


Figure 1. Geometry of piezoresponse force microscopy studies of domain switching dynamics in (a) ferroelectric films and (b) capacitors.

Shvartsman and Kholkin¹¹ in ferroelectric relaxors (see the following section) provided a basis for the statistical analysis of the domain morphology and size distributions necessary to quantify the effect of defect centers on domain evolution.

Polarization Dynamics in Ferroelectric Thin Films and Capacitors

Local studies of wall motion complement the collective domain switching studies in a uniform field of ferroelectric capacitors using the global excitation approach (Figure 1b). In this geometry, the probing tip is used to establish an electrical contact with the top electrode of a capacitor. A uniform electric field generated throughout the ferroelectric layer underneath the top electrode results in nucleation and growth of multiple domains. The electromechanical response is probed locally by scanning the electrode surface, thus providing spatially resolved information on the domain structure underneath the electrode. The global excitation geometry emulates the switching conditions in actual devices with integrated ferroelectric capacitors and allows quantitative studies of nucleation and domain wall dynamics highly relevant to the performance of these devices. Recent PFM studies revealed the inhomogeneous character of nucleation in real ferroelectrics: in a uniform field, domains nucleate in predetermined sites, likely corresponding to the local defects at the film-electrode interface¹² (Figure 2). Extension of the PFM technique to fast switching processes (in the 100-ns range) using the stroboscopic method¹³ allowed characterization of the effect of capacitor size on the rate-limiting mechanism. Specifically, a decrease in capacitor size results in a transition from nucleation-limited to wall speed-limited switching. Remarkably, due to the qualitatively different domain dynamics, capacitors of smaller dimensions ($< 1 \mu\text{m}^2$) switch

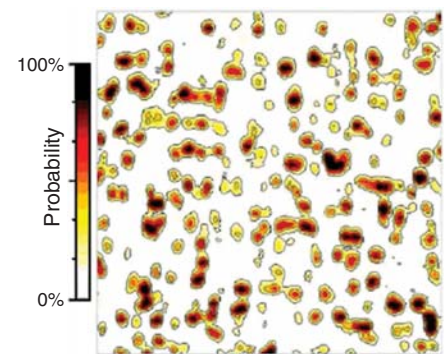


Figure 2. The spatial probability distribution of nucleation sites in a $6 \times 6 \mu\text{m}^2$ scan area in an epitaxial $\text{Pb}(\text{Zr},\text{Ti})\text{O}_3$ capacitor. Reprinted with permission from Reference 12.

faster than is predicted by the classical Kolmogorov-Avrami-Ishibashi (KAI) model in the high field range, but slower in the low fields (Figure 3).¹⁴

Observation of domain kinetics revealed strong spatial variations of wall velocities and local nucleation times in capacitors comprised of polycrystalline ferroelectric films. As a result, their switching behavior exhibits a strong deviation from the KAI switching kinetics and can be better fitted by a nucleation-limited switching model with a Lorentzian distribution of characteristic switching times.¹⁵ In contrast, canonical KAI-type domain kinetics have been observed in epitaxial capacitors because of the reduced effect of microstructural imperfections. An increase in the applied field is accompanied by a transition from lamellar domains to isotropic growth of cylindrical domains, which in terms of the switching mechanism corresponds to a change of domain switching dimensionality from one-dimensional to two-dimensional.

The PFM approach reveals novel aspects of static and dynamic behavior of polarization in nanostructures with constrained geometry, such as the strong effect of electrode shape on switching kinetics (Figure 4)¹⁶ and in-plane polarization in nominally (001) oriented lead zirconate titanate (PZT) capacitors indicative of quasi-toroidal domain structure.¹⁷ Also, inhomogeneous domain nucleation that is not bound to a defect structure—skyrmion-type dynamics¹⁸—detected in several model systems (e.g., $\text{Pb}_5\text{Ge}_3\text{O}_{11}$) sheds new light on the problem of ultimate switching speed in ferroelectrics.¹⁸

Statics and Dynamics of Domains in Ferroelectric Relaxors

Relaxors, first discovered by Smolenskii's group,¹⁹ are a special class of disordered ferroelectrics characterized by a frequency-dependent dielectric peak, glass-like behavior at low temperatures and the absence of a macroscopic transition under zero field cooling.²⁰ They possess a range of unique properties, such as a hysteresis-free electromechanical response,²¹ high dielectric constant, and outstanding electro-optic properties,²² useful for applications. In contrast to conventional ferroelectrics, relaxors do not experience a distinct phase transition into a long-range polar state with macroscopic polarization. Instead, the polarization is correlated only on a local scale where polar nanoregions (PNRs) exist. Until recently, most of the information on the size, distribution, and dynamics of PNRs could be obtained only by indirect methods, such as x-ray and neutron scattering experiments.²³ Direct observations of PNRs (e.g., by optical methods) could not succeed due to insufficient resolution.

Experiments on Ce-doped uniaxial relaxors $\text{Sr}_x\text{Ba}_{1-x}\text{Nb}_2\text{O}_6$ (SBN) demonstrated the PFM capability to resolve fine features that could not be observed with other methods.²⁴ It was shown that random electric fields due to the presence of Ce^{3+} in SBN result in the fractal-like nanodomains with a distribution described by a power law with an exponential cutoff consistent with the 2D random field Ising model (Figure 5a). The PFM spatial resolution in the 3–5 nm range allowed delineation of the domain distribution and probing of the nanodomain dynamics at low temperatures where a nonexponential decay was observed.²⁵ Significant coarsening of the nanodomain structure over time was found in the non-ergodic phase.²⁶

The nanoscale behavior is much more complicated in the Pb-based "cubic" relaxors, which include $\text{PbMg}_{1/3}\text{Nb}_{2/3}\text{O}_3$

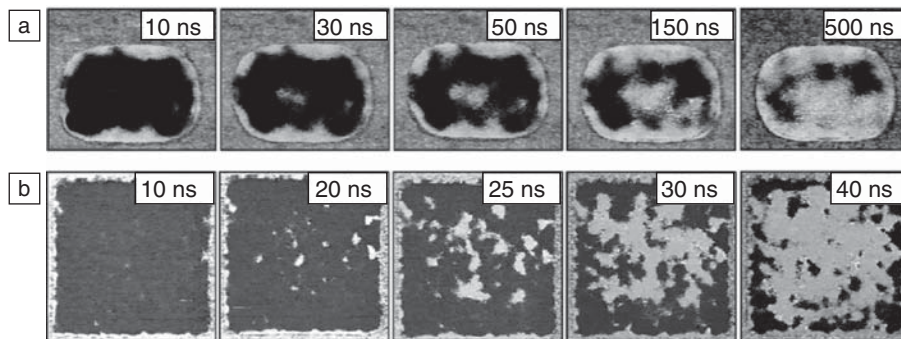


Figure 3. Piezoresponse force microscopy images of instantaneous domain configurations developing in (a) $1 \times 1.5 \mu\text{m}^2$ and (b) $5 \times 5 \mu\text{m}^2$ capacitors at different stages of the polarization reversal process for the same value of the applied field. The scanning area is $1.4 \times 1.8 \mu\text{m}^2$ in (a) and $5 \times 5 \mu\text{m}^2$ in (b). Reprinted with permission from Reference 14.

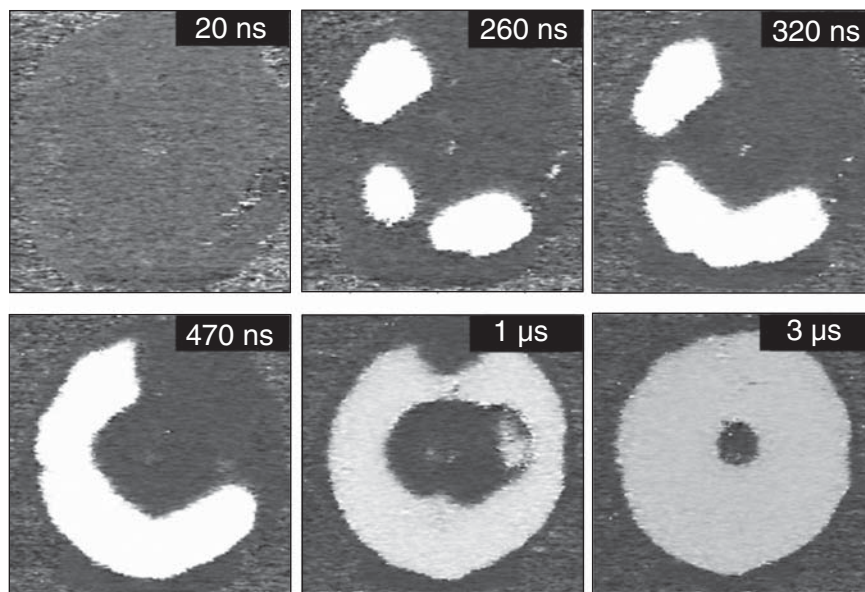


Figure 4. Piezoresponse force microscopy images of instantaneous domain configurations developing in an epitaxial circular-shape capacitor at different stages of polarization reversal. The scanning area is $1.1 \times 1.1 \mu\text{m}^2$. Reprinted with permission from Reference 16.

(PMN), $\text{PbZn}_{1/3}\text{Nb}_{2/3}\text{O}_3$ (PZN), their solutions with PbTiO_3 (PT), and relaxor ceramics $(\text{Pb}_{1-x}\text{La}_x)(\text{Zr}_{1-y}\text{Ti}_y)\text{O}_3$ (PLZT) with high La concentration. In these materials, the polarization aligns along eight equivalent [111] directions of the cubic perovskite lattice, and interpretation of the piezoresponse images is not an easy task, taking into account possible surface phase transitions²⁷ and the lack of a microscopic theory that could explain the hierarchical 2D random patterns observed by PFM. Piezoresponse images were obtained in (100)-oriented PMN–10wt%PT crystals, where the piezoresponse was analyzed by statistical (correlation) analysis of nano-

patterns.²⁸ Application of an autocorrelation function to random domain patterns allowed for the extraction of the key parameter of relaxors: the polarization correlation length (~80–90 nm at room temperature for PMN–10%PT). Both local and macroscopic symmetries could be followed from the PFM surface analysis reflecting the coexistence of different length scales in relaxors (Figure 5b and 5c).^{11,29,30} A typical example of the temperature dependence of correlation length and fractal dimension in PMN-PT is shown in Figure 5d.¹¹ Further experiments in a wide variety of relaxor systems^{31–35} established PFM as a unique method that allows

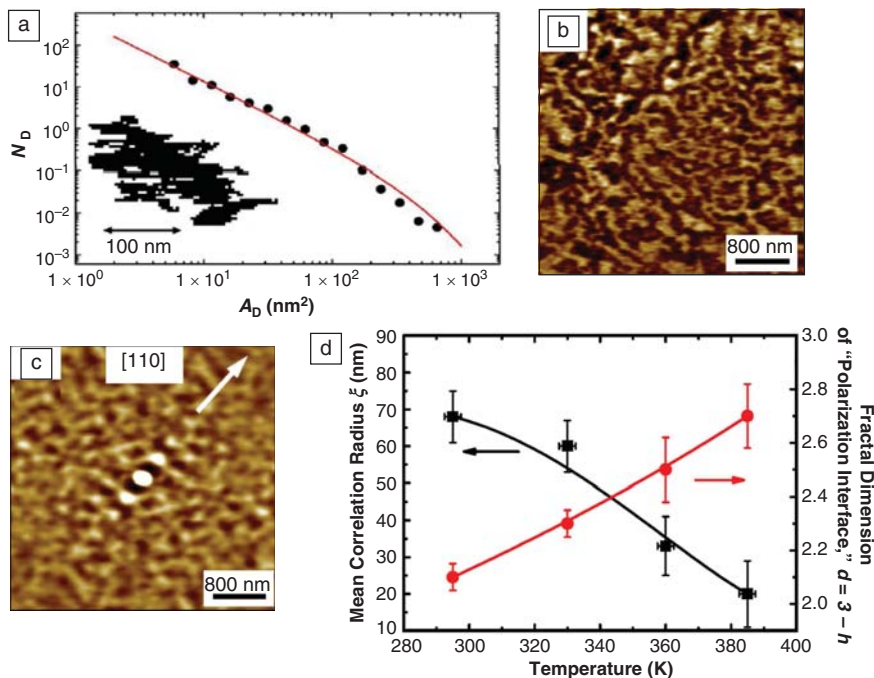


Figure 5. (a) Nanodomain distribution in uniaxial relaxor SBN:Ce.²⁴ The inset demonstrates the complicated shape of the fractal domain. (b) Piezoresponse force microscopy image of nanodomains in $\text{PbMg}_{1/3}\text{Nb}_{2/3}\text{O}_3$ -10%(PbTiO₃) (PMN-10wt%PT)¹¹ along with (c) the autocorrelation image showing alignment of nanodomains along the [110] direction. (d) Representative temperature dependence of the correlation length and fractal dimension in PMN-10%PT [11]. Reprinted with permission from References 24 and 31.

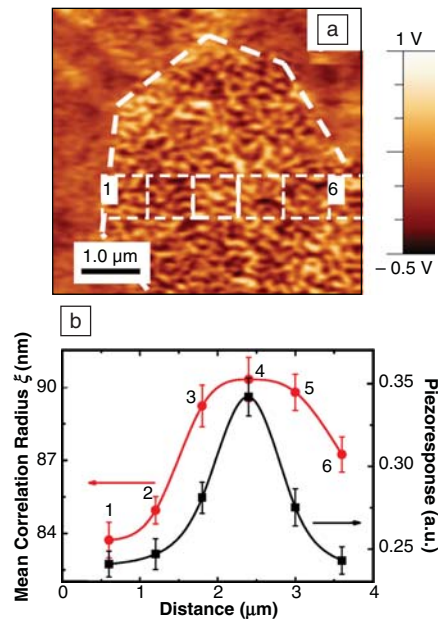


Figure 6. (a) Piezoresponse force microscopy image of nanodomains in polycrystalline $(\text{Pb}_{1-x}\text{La}_x)(\text{Zr}_{1-y}\text{Ti}_y)\text{O}_3$ illustrating the spatial distribution of the correlation length across the grain (b). Reprinted with permission from References 11 and 24.

access to many otherwise unreachable phenomena, including the grain size effect,^{33,34} local variability of the correlation length (Figure 6),³³ the role of nanodomains in the macroscopic piezoresponse,³¹ bias-induced phase transitions,^{32,36} and domain nucleation.³⁷

PFM Imaging of Functional Materials

Coupling between electrical and mechanical phenomena is common in a wide range of inorganic and organic materials, including piezoelectrics, semiconductors, polymers, biomolecules, and biological systems. The ability of PFM to probe electromechanical coupling on the nanometer scale opens a new approach to the delineation of local structure and functionality of these materials. Recently, PFM has been extensively used to study domain structures in polar III-V nitrides and biopolymers, as summarized in the text that follows.

Imaging Local Property Variations in Piezoelectric Semiconductors

The piezoelectric character of III-V semiconductors yields a novel degree of freedom in designing devices for modern

micro- and nanoelectronic applications.³⁸ As such, measurement of the piezoelectric properties in these materials with high spatial resolution is of primary importance for the design and performance of GaN-based electronic and optoelectronic devices. Development of nitride-based devices necessitates understanding the effect of interfaces, dislocations, stacking faults, and inversion domain boundaries on electrical properties. Notably, the wurtzite phase of GaN and similar materials have a sufficiently high piezoelectric response (~ 3 pm/V), which varies depending on whether Ga or N terminates the surface and on the quality of the material. The local piezoelectric coefficients thus can be used as a figure of merit for local materials structure. An example of polarization imaging is shown in Figure 7 for a GaN thin film deposited either directly on a sapphire substrate (N face) or on an AlN nucleation layer (Ga face).³⁹ By imaging GaN with PFM, it was possible to determine the quality of the interface by measuring piezoelectric coefficients, as influenced by the stress. No switching is expected in piezoelectric semiconductors since they are not ferroelectric.

Electromechanics of Biological Systems

One of the most important manifestations of electromechanical behavior is piezoelectricity, which stems from the non-centrosymmetric crystal structure of most biopolymers, including proteins and polysaccharides. Piezoelectric behavior has been observed in a variety of biological systems, including calcified and connective tissues^{40,41} and plants.^{42,43} Understanding the relationship between physiologically generated electric fields and mechanical properties on the molecular, cellular, and tissue levels has become the main motivation of studying piezoelectricity in biological systems. However, the complex hierarchical structure of biological materials combined with the strong orientation dependence of the piezoelectric effect precluded quantitative studies.

Recently, a difference in piezoelectric activity between piezoelectric proteins and nonpiezoelectric hydroxyapatite was suggested as a functional basis for high-resolution structural characterization of calcified tissues.⁸⁵ Shown in Figure 8 is the mechanical (elasticity map) and electromechanical imaging in a human

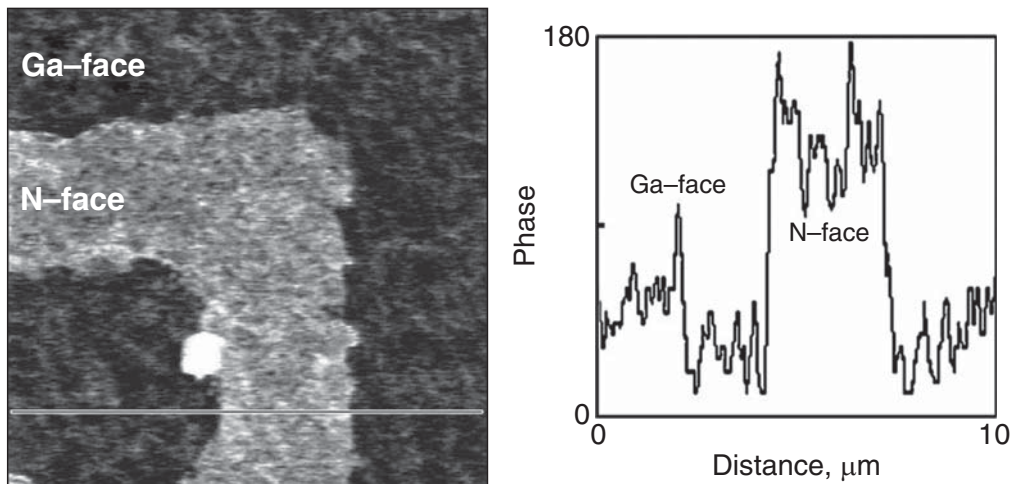


Figure 7. Piezoresponse force microscopy (PFM) phase image of Ga- and N-face regions with a corresponding cross-sectional profile taken from a horizontal line in the PFM image. The scanning area is $10 \times 10 \mu\text{m}^2$. Reprinted with permission from Reference 39.

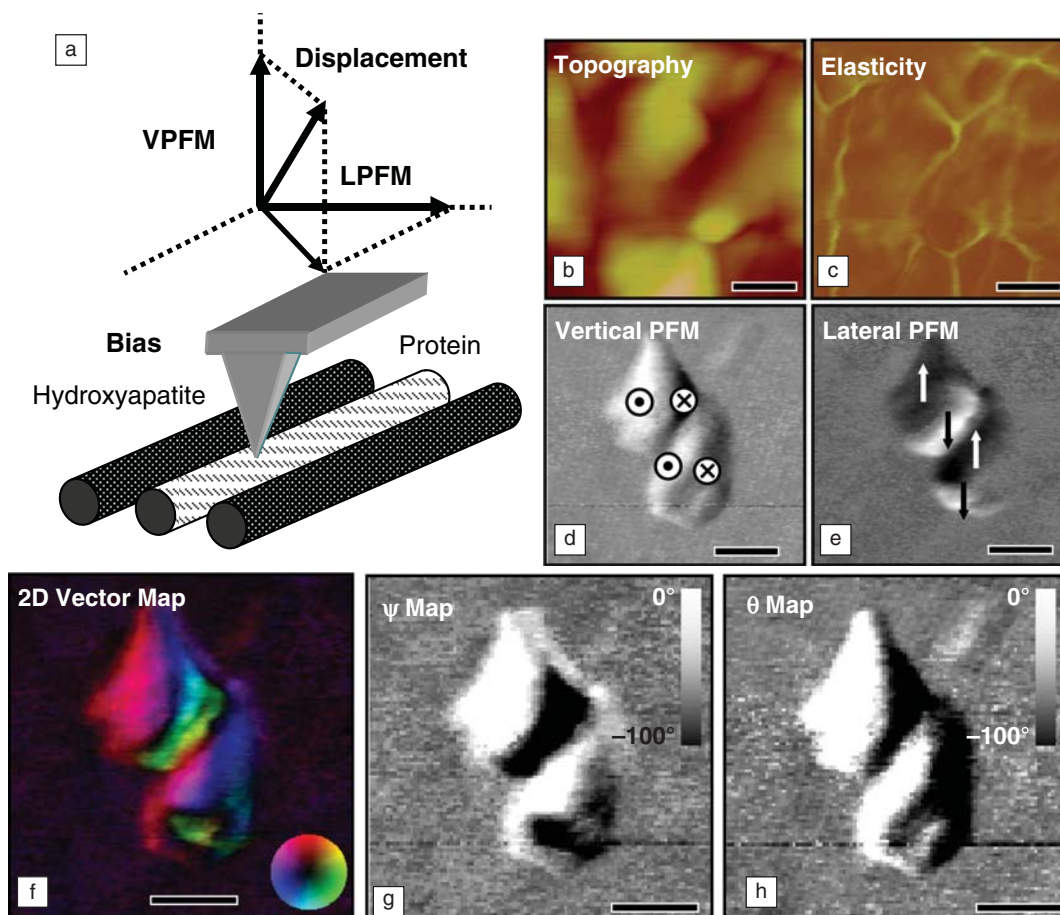


Figure 8. (a) Electromechanical response of the surface to the tip bias is a vector measure, components of which are related to the local orientation of protein molecules. In piezoresponse force microscopy, detection of vertical (VPFM) and lateral (LPFM) components of the cantilever response allows two vector components, in-plane and out-of-plane, to be simultaneously measured. (b) Surface topography (vertical scale 20 nm) and (c) an elasticity map of a $400 \times 400 \text{ nm}^2$ region on an enamel surface of a human tooth. Vertical (d) and lateral (e) PFM images of the same region. The arrows indicate the orientation of (d) out-of-plane and (e) in-plane electromechanical response, respectively. (f) Vector PFM map of a local electromechanical response. Color indicates the orientation of the electromechanical response vector in a sample plane, while the intensity provides the magnitude (color wheel diagram). (g, h) Semiquantitative map of local molecular orientation. Reprinted with permission from Reference 85.

tooth. Neither topographic (Figure 8b) nor elastic (Figure 8c) images of an enamel surface show any significant contrast difference between the grains. In comparison, both vertical PFM (VPFM) and lateral PFM (LPFM) images show a very strong electromechanical response attributed to the presence of protein (presumably amelogenin) fibrils embedded within a nonpiezoelectric hydroxyapatite matrix (Figure 8d and 8e). The spatial resolution of PFM, determined as a half-width of the boundary between different piezoelectric regions, is ~ 5 nm. Note that the resolution achieved is comparable to the best results to date achieved for thin films of ferroelectric perovskites. Comparison of the VPFM and LPFM images shows a different pattern of piezoelectric domains, suggesting a complicated structure of the fibrils, consisting of several protein molecules. The color encoded vector piezoresponse map (vector PFM), shown in Figure 8f, clearly delineates the helical structure, visualizing the electromechanically active protein fibril conformation in real space.

PFM Manipulation and Lithography

Patterning ferroelectric domains to engineer devices is a relatively recent phenomenon. In the early 1990s, the literature on patterning nonlinear optical materials with a variety of macroscopic approaches evolved. The goal was to use periodic variations in the dielectric constant to realize quasi-phase matching for applications involving optical wave guiding, second-harmonic generation, and surface acoustic wave devices. For these applications, typical feature sizes are on the order of several micrometers. Simultaneously, advances in thin-film deposition techniques and the invention of PFM converged to suggest a potential for nanometer-sized domain manipulation with high spatial resolution.⁴⁴ The two primary avenues that exploit PFM in the manipulation of ferroelectric polarization are nanostructure fabrication and high-density information storage, as summarized in the following text.

High-Density Data Storage

The PFM capability of effective control of ferroelectric domains stimulated efforts on the generation of domain structures for applications in high-density data storage and nanofabrication. Several groups reported generation of regular domain patterns with nanoscale periodicity in ferroelectric PZT thin films, LiTaO_3 , BaTiO_3 , and $\text{Sr}_{0.61}\text{Ba}_{0.39}\text{Nb}_2\text{O}_6$ single crystals using PFM^{45–48} (Figure 9a and 9b).

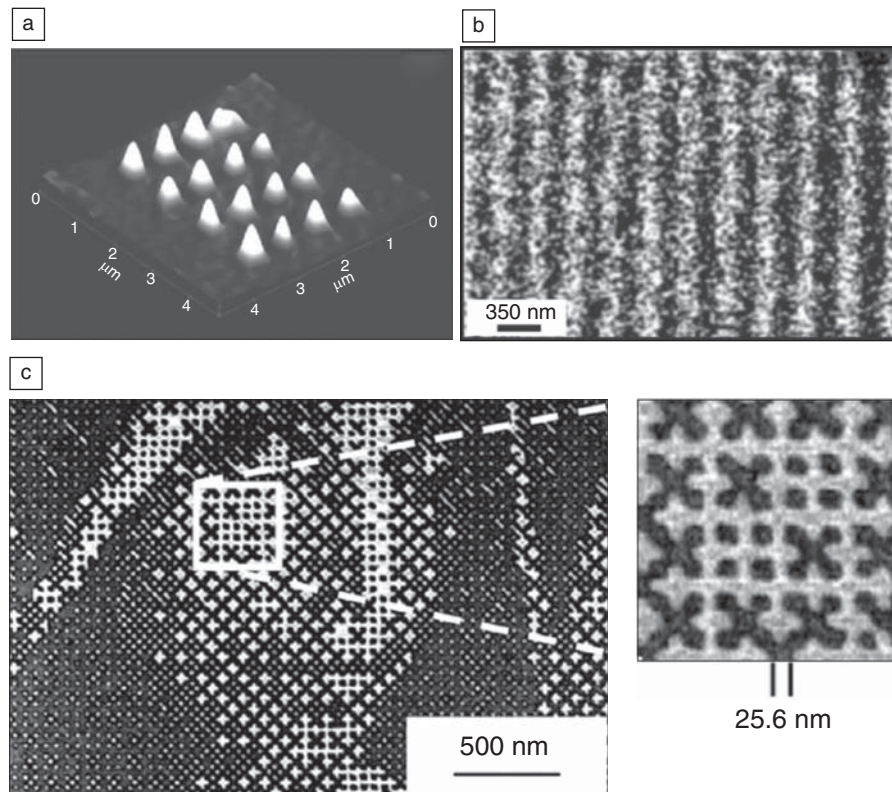


Figure 9. Piezoresponse force microscopy-imaged nanoscale domain patterns in single crystals of (a) BaTiO_3 , (b) $\text{Sr}_{0.61}\text{Ba}_{0.39}\text{Nb}_2\text{O}_6$ (reprinted with permission from Reference 48), and (c) LiTaO_3 (reprinted with permission from Reference 53).

Application of PFM for data storage is based on performing both “write” and “read” operations. The “write” operation is performed while contacting the sample surface with a biased tip and inducing local 180° polarization switching, orienting polarization downward or upward. The “read” step involves PFM phase detection of written domains. Alternatively, domains can be read-out using resistive probes^{49,50} or by monitoring the nonlinear dielectric response. In the case of resistive detection, the electrostatic field of the written domain depletes or accumulates the carrier inside the low-doped region of the resistive probe. The written domains are detected as a change in the resistance between the two highly doped terminals formed on both sides of the tip. The scanning nonlinear dielectric microscopy approach employs a special resonator probe operating in the microwave frequency range.⁵¹ Point-to-point detection of the local voltage-induced change in the sample capacitance allows nanoscale domain imaging in a surface layer of about 10-nm thick. Given that the width of domain walls in ferro-

electrics is typically very small (of the order of 1–3 unit cells), this ferroelectric recording potentially allows extremely high data storage densities, well above that of conventional magnetic recording.⁵² A ferroelectric bit size of 8 nm in diameter corresponding to 10 Tbit/inch² storage density was demonstrated in 40-nm thick single crystals of lithium tantalate (Figure 9c).⁵³ These developments generated significant interest from major corporations, such as IBM, Samsung, and Canon, toward SPM-based ferroelectric data storage.⁵⁰

PFM-Assisted Nanofabrication

Switching of ferroelectric polarization beneath the PFM tip is analogous to macroscopic poling with the advantages of localization to small areas under the tip and of the facile patterning capability inherent in SPM. Because features can be structured with nanometer dimensions, an obvious application of PFM-based domain patterning is as a template for fabricating nanoscale structures.⁵⁴ The underlying mechanism for domain-specific reactivity follows from the fact that a fer-

roelectric domain terminates at a surface with a charge. This charge influences the local electronic structure. In the vernacular of semiconductors, the valence bands and conduction bands bend up at a surface with a negative charge and down at a surface with a positive charge (for the case of intrinsic n -type carriers) (Figure 10). The difference in the energy levels of these bands (or bonds) results in different physical and chemical reactivity. Many examples of the effects of domain orientation on molecular interactions have been documented.^{55–57} Most ferroelectric compounds are insulators or wide-gap semiconductors, and thus to engage any reactions involving electrons, carriers must be created. This is easily accomplished through the absorption of super bandgap UV light. Electrons and holes formed upon optical absorption will separate in the electric fields, with electrons moving to positive domains and holes to negative domains.⁵⁸ These carriers are then localized and available for reactions at the surface.

These factors are controlled in a process referred to as ferroelectric nanolithography, which achieves the fabrication of complex multicomponent assemblies.⁶¹ First, the polarization orientation is patterned on a surface. In order to achieve precise structures, a background is often poled in the orientation that will not react before the reaction pat-

tern is produced. After patterning, the substrate is placed into an aqueous metal salt solution and irradiated by super bandgap UV light. Photo reduction or oxidation occurs on the appropriate domains. By controlling the reaction conditions, it is possible to produce patterns with 3–10-nm particles in 1D arrays or build 3D structures with multiple layers of nanoparticles, to simultaneously and sequentially deposit different nanoparticles, and to produce organic/inorganic hybrid structures. The process is general in that it has been applied to single-

crystal and thin-film oxide substrates, thin-film ferroelectric polymer substrates, and involved reaction products from oxidation and reduction reactions. Nanostructures have involved noble metals (Pt, Pd Au, Ag), Ni and Co oxides, magnetic nanoparticles, and porphyrin molecules.^{60–62}

Figure 11 illustrates various aspects of ferroelectric nanolithography. Patterning on PZT and PVDF thin films are illustrated in Figure 11a and 11b, respectively. Deposition due to the reduction of Ni (Figure 11c) and oxidation of Co (Figure 11d)

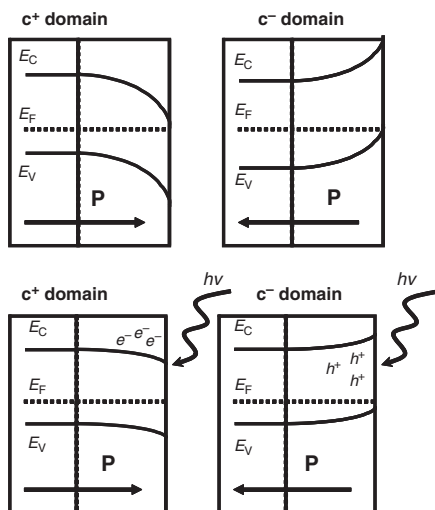


Figure 10. Schematic diagram of the energy bands during photodeposition of nanoparticles on ferroelectric substrates. E_c , conduction band energy level; E_v , valence band energy level; E_f , Fermi energy level; h , Planck's constant; ν , frequency of incident beam.

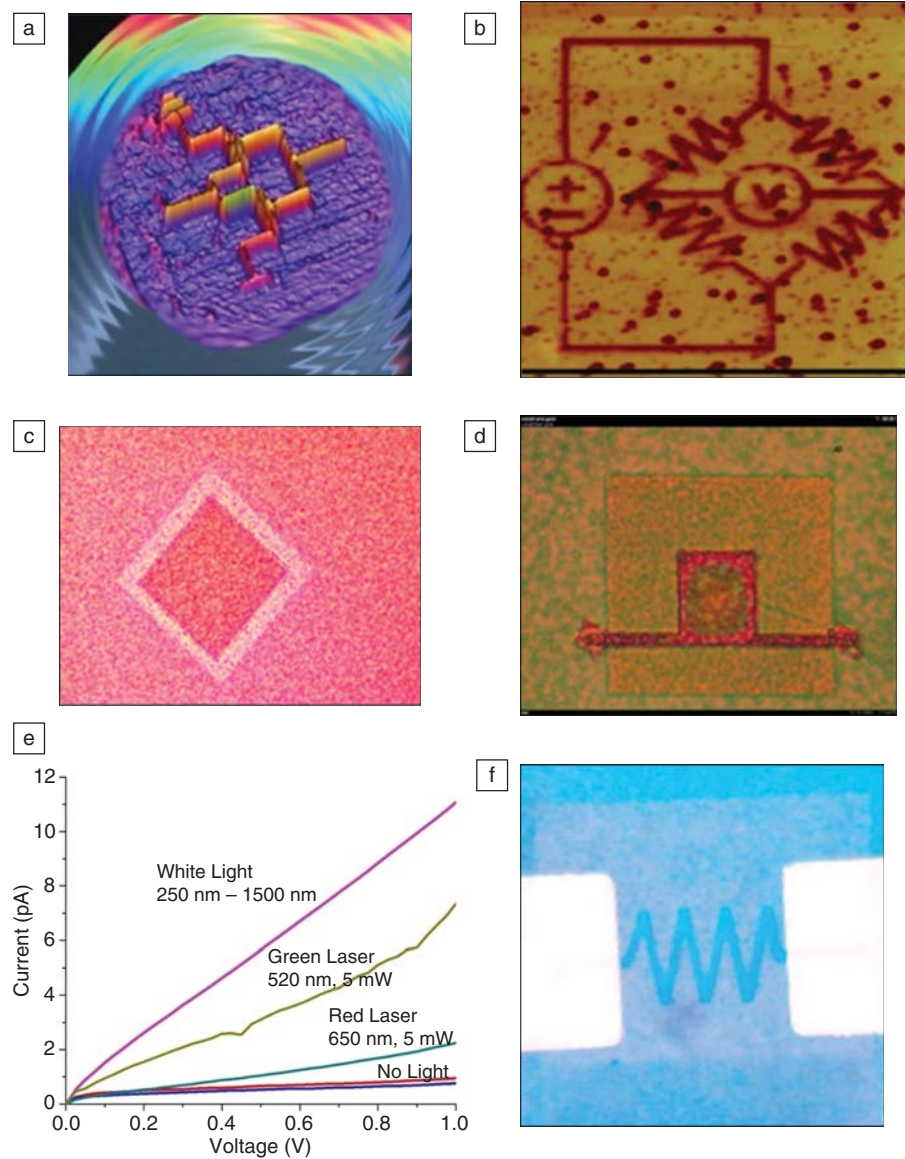


Figure 11. Domain patterning on (a) oxide and (b) polymer ferroelectric surfaces; (c) deposited Ni nanoparticles and (d) oxidized Co and reduced Au on the same surface; (e) demonstration of opto-electronic properties of patterned Au on lead zirconate titanate with functional porphyrins; and (f) device configuration patterns.

are compared, and subsequent deposition of an oxidation product Co^{2+} and reduction product Ag is demonstrated in Figure 11d. Patterning of hybrid nanostructures with optoelectronic device properties is illustrated in Figure 11e and 11f. In this case, an Au nanoparticle array is functionalized with a porphyrin complex to produce a wavelength-dependent current. The generality of this approach combined with the potential for high spatial resolution portends applications ranging from sensing to catalysis.

Future Pathways for PFM-Based Data Storage and Nanofabrication

For successful application of the domain-based approach to data storage and nanolithography, several key issues related to the scale of domain engineering should be addressed. First, reproducibility of high-resolution domain writing is necessary for fabrication of reliable, large-scale ferroelectric templates. This requirement critically depends on the uniformity of the static and dynamic properties of the ferroelectrics at the nanoscale.⁶³ Investigations of the statistical variations in domain sizes as a function of the sample microstructure, dielectric properties, and domain writing conditions are necessary to identify the optimum type of ferroelectric recording media. It has been shown that the bits in a 128×82 data set could be stored in a statistically reliable way, with a bit error rate of 1.8×10^{-2} in single-crystalline lithium tantalate (Figure 9c).⁵³ In polycrystalline ferroelectric thin films, the effect of grain size and crystallographic orientation on spatial uniformity and reproducibility of the domain writing needs to be taken into account. Fabrication of high-quality ferroelectric nanomesas may be one of the possible solutions to this problem.^{64,65}

Second, long-term stability of the written domain patterns is a key requirement necessary for data storage. This problem is closely related to the problem of thermodynamic stability of the ferroelectric phase at the nanoscale. One of the most important factors affecting domain stability is the screening of spontaneous polarization, which is a complex function of interface quality, electrode materials, microstructure, and ambient environment. It has been found recently, that ferroelectric films as thin as 1.6 nm (two unit cells) still exhibit ferroelectric behavior.⁶⁶ PFM studies of domains in ultrathin films can contribute to better understanding of the size effects and stability issues in ferroelectrics.

Third, and probably the most serious problem for the use of PFM-based data storage is throughput,⁶⁷ which is limited by the tip scanning rate. While the write speed in ferroelectrics can be in the nanosecond range, the typical scanning speed of most scanning probe microscopes is in the range of tens of microns per second. The likely solution of this problem lies in the use of massive parallelism, as has been recently demonstrated by the IBM Millipede concept.⁶⁸ High data rates have been achieved through the use of large (32×32) 2D arrays of PFM probes, which operate simultaneously. Recently, a multiple-tip array has been used to generate a regular one-dimensional domain grating in 200- μm -thick RbTiOPO_4 ferroelectric crystals.⁶⁹ Another speed-limiting factor is the response time of the probe, which measures the interaction force with the sample. Utilizing a special cantilever with a passive mechanical feedback loop operating in the MHz range and a microresonator as a scan stage allows a 1000-fold increase in pixel acquisition rate relative to a conventional AFM,⁷⁰ which is an encouraging development for throughput improvement of the SPM-based fabrication methods.

Switching Spectroscopy by PFM

Along with the sequential polarization switching studies performed with a series of voltage pulses applied to the tip followed by domain imaging, PFM can be used in a spectroscopy mode when the switching measurements are done locally using a probing tip fixed at a certain location on a bare sample surface. This approach, called piezoresponse force spectroscopy (PFS), produces local electromechanical hysteresis loops related to the process of a single domain formation under the tip. Because of the extremely small size of the volume excited during PFS measurements ($\sim 10^3$ – 10^5 nm^3), PFS offers a unique possibility of studying the role of individual nano- and atomic-scale defects in switching. As such, PFS hysteresis measurements convey information differently than those related to hysteresis loops that are measured in capacitor structures, which reflect a multitude of nucleation events occurring within an extended period of time.^{71,72} The PFS hysteresis loops often contain reproducible fine structure features (kinks) somewhat similar to structures in force-distance curves in AFM. The studies by Alexe's group have associated the presence of the fine structure features with their proximity to a ferroelastic domain wall.^{73,74} BdiKin et al.⁷⁵ have performed simultaneous imaging and spectroscopic

studies and illustrated that the fine structure is associated with non-monotonic jumps in wall motion (i.e., individual pinning events).

A recent extension of PFS is switching spectroscopy PFM (SS-PFM),⁷⁶ in which hysteresis curves are collected at each point in an image and stored in a 3D data array. Phenomenological parameters describing the switching process, such as positive and negative coercive bias, imprint voltage, and saturation response, can be extracted from the data sets and plotted as 2D maps of spatially resolved switching properties that can be correlated with PFM and surface topography.⁷⁷ Recently, SS-PFM and PFS have been used to study intrinsic polarization switching on a defect-free surface,⁷⁸ to reconstruct the frozen polarization layers in PZT nanoparticles,⁷⁹ and to map disorder potential components in epitaxial ferroelectric thin films.⁸⁰ Notably, in high-quality epitaxial films, the spatial separation between extended defects such as dislocations can exceed 100 nm,⁸¹ as compared to the ~ 10 – 30 -nm size of domains detectable by PFM. This comparison suggests that switching can potentially be studied on the level of a single defect.⁸² The combination of SS-PFM on artificially engineered defect structures in a bicrystal grain boundary with phase field modeling⁸³ has provided the ability to decipher deterministic mesoscopic polarization switching in ferroelectrics (Figure 12).

General Outlook

While one's initial impression of electromechanical interactions may be that they are significant only in ferroelectric compounds, this is not true. Coupled electromechanical properties are inherent in hundreds of inorganic materials and similarly in biological materials. The evolution of piezoresponse force microscopy (PFM) provides a new window into the behavior of a wide range of materials.

Equally important, the developments in PFM are part of a larger trend toward extreme high-spatial resolution in the quantification of electromagnetic properties.⁸⁴ Several classes of properties are now probed at subnanometer resolution. In most cases, the properties are represented by single scalar numbers, such as resistance, conductance, potential, and work function. PFM is unique in that it carries this strategy into the realm of complex tensor properties. We can expect significant advances both in the areas of materials and device characterization and in patterning and lithography.

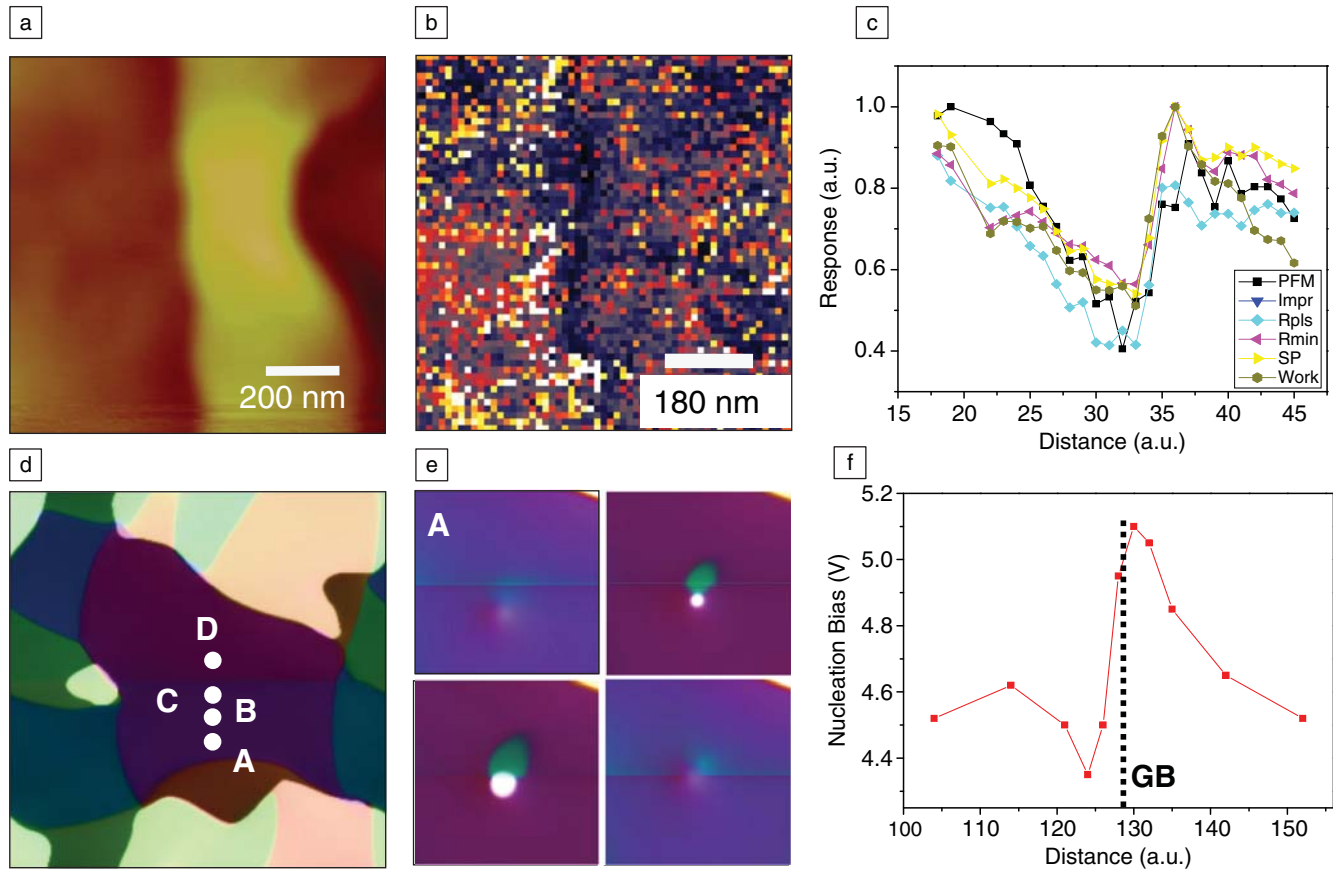


Figure 12. (a) Surface topography and (b) switching spectroscopy-piezoresponse force microscopy nucleation bias map of a BiFeO_3 24° (100) bicrystal grain boundary (GB). Each point in (b) is a hysteresis loop. (c) Ferroelectric switching properties across the interface. (d) Phase field modeling of domain structure. (e) Polarization distributions induced by the tip at 4.5 V bias for locations in (d). (f) Spatial distribution of nucleation voltage across the GB. Rodriguez et al., *Adv. Func. Mater.* **19**, 1 (2009).

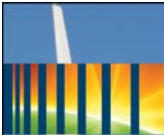
Acknowledgments

SVK acknowledges support from the division of Scientific User Facilities, DOE, BES. ALK is grateful to the Fundação para a Ciência e a Tecnologia (Portugal) for the financial support within national projects PTDC/FIS/81442/2006 and PTDC/CTM 73030/2006.


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